Hiden *MAXIM* Quadrupole SIMS Analyser



ANALYTICAL

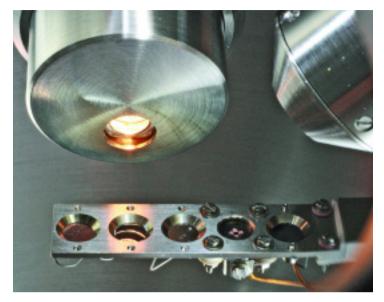
Vacuum analysis

surface science

plasma diagnostics

Gas analysis

MAXIM Overview



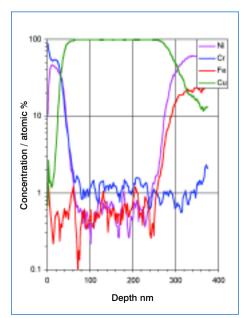
The Hiden MAXIM quadrupole SIMS analyser is a state of the art secondary ion mass spectrometer for static and dynamic SIMS applications.

The MAXIM analyser system includes an integral energy filter for ion acceptance at 30° to the probe axis, high transmission SIMS extraction ion optics, triple mass filter, pulse ion counting detector, and control electronics with Windows MASsoft PC software.

SNMS

Sputtered Neutral Mass Spectrometry

At the front of the MAXIM is an electron bombardment ionizer which is used to ionize neutral species. The separation of sputtering and ionization processes means that matrix effects are minimised which



results in easy quantification of alloys and high concentration impurities, without the need of matrix matched reference materials.

The example shows a quantified depth profile through a NiCr/Cu/NiFe layer structure. The primary ions were 5 keV Ar+ from the Hiden IG20 gas ion gun.

MAXIM technology... at a glance

SIMS

Secondary Ion Mass Spectrometry SIMS is the most sensitive surface analysis technique and possesses a very high dynamic range. It is ideally suited to the analysis of impurities and dopants to well below ppm concentration. Ions generated by the sputtering process are collected by the extraction field and transferred to the MAXIM's triple filter for mass analysis.

Depth Profiling

As SIMS simultaneously sputter erodes and detects the ion signal, it is an ideal technique to rapidly produce depth profiles of species of interest. Here Mg⁺ secondary ions were detected from a 100keV Mg implant into silicon. The primary ions were 5keV oxygen from the Hiden IG20 gas ion gun.

Surface Contamination

Using a very low ion dose, such that sputter erosion is minimal, the detected material is characteristic of only the uppermost monolayers – static SIMS.

The spectrum below was taken from a silicon wafer that had been processed in a chamber previously contaminated with gold and silver. Low levels of these metals are detected in negative ion mode, together with hydrocarbons and residues of a chlorinated cleaning agent. The primary ions were 3 keV Cs⁺ from the Hiden Caesium ion gun.

MAXIM technical specifications

MAXIM the most sensitive quadrupole SIMS analyser for the most sensitive elemental analysis technique.

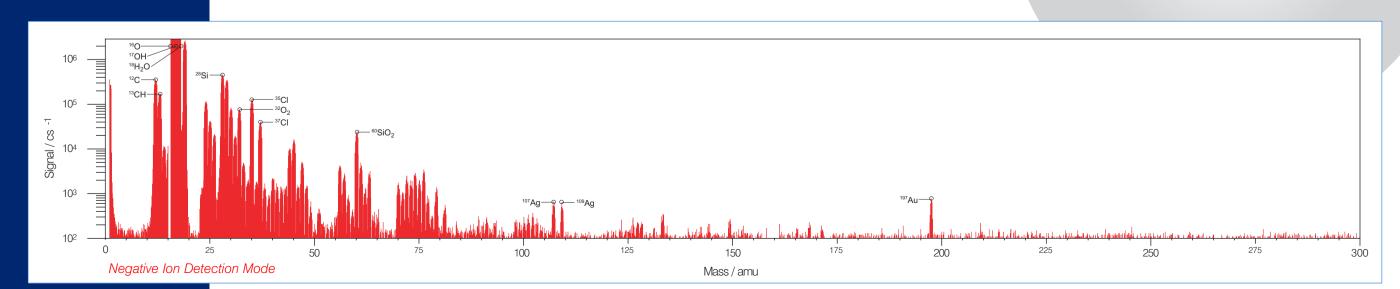
Secondary ion intensity – greater than $3x10^6$ cps/nA for $^{27}AI^+$ with 5keV argon primary ions.

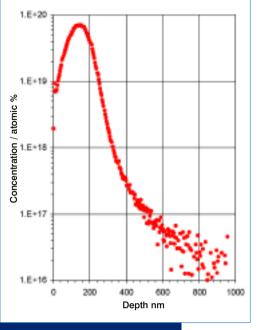
Cs Gun

Useful yield – 0.02% Boron in Silicon 5kev Oxygen primary.

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MAXIM





software control

MASsoft Windows PC based software with:

- Pre-set modes for positive and negative ion SIMS and SNMS
- Raster control of primary ion gun to define ion beam scan area

Optional:

- SIMS Imaging software
- Acquires, displays and stores SIMS elemental maps

specifications

Mass range	300amu, 500amu or 1000amu.
Detector	lon counting detector Positive and Negative ion detection Max count rate 10 ⁷ cps
Mass filter	Triple filter
Pole diameter	9mm
Bakeout	250°C
lon energy filter	30° angular acceptance
loniser	Electron bombardment, single filament for SNMS and RGA

Other products for Surface Technologies

SIMS on a Flange



IG20 Gas Ion Gun



NAX N





Manufactured in England by: HIDEN ANALYTICAL LTD 420 EUROPA BOULEVARD WARRINGTON, WA5 7UN, ENGLAND Tel: +44 (0)1925 445225 Fax: +44 (0)1925 416518 Email: info@hiden.co.uk Web Site: www.HidenAnalytical.com It is Hiden Analytical's policy to continually improve product performance and therefore specifications are subject to change.

TECHNICAL DATA SHEET 164